

PATENT ABSTRACTS OF JAPAN

(11)Publication number : 2003-155561

(43)Date of publication of application : 30.05.2003

(51)Int.Cl.

C23C 14/34
C22C 5/06
G11B 7/24
G11B 7/26
G11B 11/105

(21)Application number : 2001-352594

(71)Applicant : MITSUBISHI MATERIALS CORP

(22)Date of filing : 19.11.2001

(72)Inventor : MISHIMA TERUSHI

(54) SILVER ALLOY SPUTTERING TARGET FOR FORMING REFLECTION LAYER OF OPTICAL RECORDING MEDIUM**(57)Abstract:**

PROBLEM TO BE SOLVED: To provide a silver alloy sputtering target for forming an Ag alloy reflection layer of an optical recording medium such as a magneto-optical recording disk (MD, MO) and an optical recording medium (CD-RW, DVD-RAM).

SOLUTION: This sputtering target consists of: a silver alloy (1) having a composition containing, by mass, 0.5 to 3% Cu and one or more kinds selected from Dy, La, Nd, Tb and Gd by 0.1 to 3% in total, and the balance Ag; a silver alloy (2) having a composition containing 0.5 to 3% Cu, and one or more kinds selected from Ca, Be and Si by 0.005 to 0.05% in total, and the balance Ag; or a silver alloy (3) having a composition containing 0.5 to 3% Cu, and one or more kinds selected from Dy, La, Nd, Tb and Gd by 0.1 to 3% in total, and one or more kinds selected from Ca, Be and Si by 0.005 to 0.05% in total, and the balance Ag.

LEGAL STATUS

[Date of request for examination] 29.09.2003

[Date of sending the examiner's decision of rejection]

[Kind of final disposal of application other than the examiner's decision of rejection or application converted registration]

[Date of final disposal for application]

[Patent number]

[Date of registration]

[Number of appeal against examiner's decision of rejection]

[Date of requesting appeal against examiner's decision of rejection]

[Date of extinction of right]

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